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RESPONSE UNDER 37 C.F.R. § 1.116  
-- EXPEDITED PROCEDURE --  
EXAMINING GROUP 1700

Our Docket No.: 42P19023

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

Donghul Lu

Application No.: 10/811,591

Filed: March 29, 2004

For: Enhanced Dielectric Layers Using  
Sequential Deposition

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) Examiner: Gambetta, Kelly M.  
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) Art Group: 1792  
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**RESPONSE AFTER FINAL**

Mail Stop AF  
Commissioner for Patents  
P.O Box 1450  
Alexandria, VA 22313-1450

Sir:

In Response to the Final Office Action mailed August 27, 2009, Applicants respectfully request the Examiner to enter the following amendment and to consider the following remark.

**CERTIFICATE OF EFS Web**

I hereby certify that this correspondence is being submitted electronically via EFS Web on the date shown below to the United States Patent and Trademark Office.

Date of Deposit: September 11, 2009

Name of Person Mailing Correspondence: Debbie Casias

/Debbie Casias/ /September 11, 2009/  
Signature Date